

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Inventor(s) : Franz LAERMER et al.  
Serial No. : 10/524,610  
Filed : August 11, 2005  
For : LAYER SYSTEM HAVING A SILICON LAYER AND A  
PASSIVATION LAYER, METHOD FOR CREATING A  
PASSIVATION LAYER ON A SILICON LAYER AND ITS  
USE  
Examiner : Hoang Ho  
Art Unit : 2818  
Confirmation No. : 9981

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Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

**AMENDMENT UNDER 37 C.F.R. § 1.116**

S I R:

In response to the Final Office Action of August 2, 2010, for which the three-month response date expires on November 2, 2010, kindly amend the above-captioned application without prejudice as follows:

**Amendments to the Claims** are reflected in the listing of claims, which begins on page 2 of this paper.

**Remarks** begin on page 4 of this paper.